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|  | anoushka.n | | | | | | | |  |
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|  | WEB DEVELOPMENT AND TECHNICAL JOBS | | | | | | | |  |
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|  | CONTACT |  |  | PROFILE |  | | |  |  |
|  | Avadi, Chennai-6000719043685052www.linkedin.com/in/anoushkany[anoushkany86@gmail.com](mailto:anoushkany86@gmail.com) **SOFT SKILLS**   * Adaptability and flexibility. * Critical thinking and problem solving ability | |  | Computer science enthusiast with a strong background in programming and data analysis. Seeking a role to apply technical skills and drive innovation. Committed to continuous learning and contributing to impactful projects.  **NOTE**: Completed 2 semesters (UG) without any arrears. | | | | |  |
|  | TECHNICAL SKILLS |  |  | EXPERIENCE | |  | |  |  |
|  | HTMLCSSPythonJavaWeb DevelopmentWeb page  * Typewriting skill * Poster making * Logo making | |  | Worked on a generative AI project with tools of artificial intelligent. On topic “NEXTSENSE”.Created static webpage on tourism.  1. Presented a business plan at SA arts and science college on topic”Seefy”. 2. Presented case study analysis of green organic industry. 3. Presented a construction and perfume company logo at SRM college.   **COURSES**   1. Coding practice on python offered by Infosys. 2. English communication training offered by Naan Mudhalvan.   **ACHIEVEMENTS** Best logo making award of the batch 2023-2026.  1. Awarded case study and logo making in SRM Institution.   **PAPER PRESENTATION** Presented papers on the topics Dart Programming Language, Seefy and NEXTSENSE at SA college of arts and science and SRM Institution.PERSONAL DETAILS **Date of Birth** : 21st February, 2006  **Language known** : English. Tamil, Spanish.  **Hobbies**  : Reading books and Writing books.  **Gender**  : Female | | | | |  |
|  | EDUCATION |  |  |  |
|  | Mahalashmi women’s college of arts and science2023-2026 BSc.,Computer Science. Nxtwave technology2024-2027 4.o technologies.  **EDUCATIONAL QUALIFICATION**     * **SSLC :** 96 Percentage * **HSC+2 :** 81 Percentage * **BSc.CS :**   SEMESTER 1-89 Percentage  SEMESTER 2-90 Percentage | |  |  |